

PATENT
Docket No. 150.0056 0104

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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|--|---|-----------------|------|
| Applicant(s): Whonchee Lee et al. |) | Group Art Unit: | 1765 |
| |) | | |
| Serial No.: 10/050,639 |) | Examiner: | Deo |
| Confirmation No.: 6476 |) | | |
| |) | | |
| Filed: 15 January 2002 |) | | |
| |) | | |
| For: METHOD AND COMPOSITION FOR SELECTIVELY ETCHING AGAINST COBALT SILICIDE |) | | |

RESPONSE

Assistant Commissioner for Patents
Washington D.C. 20231

Dear Sir:

In response to the Office Action dated 9 April 2002, please consider the following remarks:

Remarks

The Office Action dated 9 April 2002 has been received and reviewed. Reconsideration and withdrawal of the rejections are respectfully requested.

Allowed Subject Matter

Applicants acknowledge that claims 68-75 are allowed.

Objected to Subject Matter

Applicants acknowledge that claims 47-49 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims. However, Applicants have not rewritten claims 47-49 at this time because it is believed that claim 46, from which claims 47-49 ultimately depend, is in allowable form.

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